



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re ~~application~~ of:

Thomas A. Figura, Kevin Donohoe, & Thomas Dunbar

Serial No.: 09/471,460

Filed: December 22, 1999

# Title: USE OF A PLASMA SOURCE TO FORM A LAYER DURING THE FORMATION OF A SEMICONDUCTOR DEVICE

AMENDMENT AFTER THE CONTINUED PROSECUTION APPLICATION  
AND RESPONSE TO THE OFFICE ACTION DATED JUNE 6, 2000

Assistant Commissioner for Patents  
Washington, D.C. 20231

Dear Sir:

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THE ASSISTANT COMMISSIONER FOR  
WASHINGTON, D.C. 20231  
*Eric B. Werner - Director*  
Signature

Applicants submit this Amendment and Response to the Office Action dated June 6, 2000. Please amend the accompanying continued prosecution application as follows.

## IN THE SPECIFICATION

In the section labeled "RELATED APPLICATIONS" added in the Preliminary Amendment, please add at the end of that section the following:

-- This application contains subject matter related to U.S. application Ser. No. 09/470, 650, which is also a divisional of pending U.S. application Ser. No. 09/046,835 mentioned above.